



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT(S): Mitsuhiro Nakamura et al.

ATTORNEY DOCKET NO.:
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SERIAL NO.: 08/809,463

GROUP ART UNIT: 2814

FILED: July 18, 1997

EXAMINER: Phat X. Cao

INVENTION: "MULTI-LAYERED STRUCTURE FOR FABRICATING AN
OHMIC ELECTRODE AND OHMIC ELECTRODE"

Mail Stop: RCE
Commissioner for Patents
Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed herewith is an RCE and a 2 Month Extension of Time of Mitsuhiro Nakamura et al. for the above-identified patent application entitled: MULTI-LAYERED STRUCTURE FOR FABRICATING AN OHMIC ELECTRODE AND OHMIC ELECTRODE.

Enclosed are: RCE Transmittal Form
2 Month Extension of Time Transmittal
Credit Card Payment Form
Certificate of Mailing
Postcard

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The Commissioner is hereby authorized to charge any additional fees required, as well as any patent application processing fees associated with this communication for which full payment has not been tendered, to Deposit Account No. 19-3140.

Respectfully submitted,

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